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IN THE UNITED STATES DISTRICT COURT  
FOR THE DISTRICT OF HAWAII

MARTIN DEFENSE GROUP, LLC,  
AND NAVATEK HOLDINGS LLC

Plaintiffs,

v.

MARTIN KAO; TIFFANY JENNIFER  
LAM a.k.a. JENNY LAM and/or  
TIFFANY KAO; LAWRENCE  
KAHELE LUM KEE; CLIFFORD  
CHEN; GARY AMBROSE; DUKE  
HARTMAN; SOCIETY OF YOUNG  
WOMEN SCIENTISTS AND  
ENGINEERS LLC,

Defendants.

Case 1:22-cv-00283-LEK-WRP

DEFENDANTS MARTIN KAO,  
TIFFANY JENNIFER LAM aka  
JENNY LAM and/or TIFFANY  
KAO, AND SOCIETY OF YOUNG  
WOMEN SCIENTISTS AND  
ENGINEERS, LLC'S FRCP RULE  
7.1 DISCLOSURE STATEMENT

**DEFENDANTS MARTIN KAO, TIFFANY JENNIFER LAM aka JENNY LAM and/or TIFFANY KAO, AND SOCIETY OF YOUNG WOMEN SCIENTISTS AND ENGINEERS, LLC'S FRCP RULE 7.1 DISCLOSURE STATEMENT**

Pursuant to FRCP Rule 7.1, DEFENDANTS MARTIN KAO, TIFFANY JENNIFER LAM aka JENNY LAM and/or TIFFANY KAO, AND SOCIETY OF YOUNG WOMEN SCIENTISTS AND ENGINEERS, LLC make the following disclosures: SOCIETY OF YOUNG WOMEN SCIENTISTS AND ENGINEERS, LLC, is not a corporation and does not have a parent corporation and is not owned in whole or in part by any corporation.

DATED: Honolulu, Hawaii, August 29, 2022.

/s/ Chuck C. Choi  
KEITH M. KIUCHI  
CHUCK C. CHOI  
ALLISON A. ITO  
MICHEL A. OKAZAKI  
ATTORNEYS FOR DEFENDANTS  
MARTIN KAO, TIFFANY LAM AND  
SOCIETY OF YOUNG WOMEN SCIENTISTS  
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